ERRATUM

1. Page 15. It is written "...or $\mu_i^a = \mu_i^b = ... = \mu_i^\phi = 0". It should be "...or $\mu_i^a = \mu_i^b = ... = \mu_i^\phi".

2. Page 23. There is an extra space before the subscript in TaSi$_2$ in Fig. 5.

3. Page 36. 1, 2, A and layer 3 in Fig. 9 refer to the SEM micrograph in the original paper, and have no meaning here. Therefore, they should be ignored.

4. Appendix I page 64. The annealing ambient should be $10^{-4}$ Pa.

5. Appendix III page 2939. Jyrki has been misspelled.

6. Appendix III page 2945. Valtion has been misspelled.

7. Appendix IV page 3. It is written "...(about 20-30 $\mu$m in diameter)". It should be "...(about 20-30 $\mu$m in diagonal)."

8. Appendix V page 3. It is written "... films were sputtered onto cleaned..." it should be "... films were sputter-deposited onto cleaned...".